

L Number	Hits	Search Text	DB	Time stamp
19	0	2-mercaptothiazole and solvent and resin and ((photoacid acid) near generator) and (basic adj compound)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/05 16:08
20	299	2-mercaptothiazole	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/05 16:03
21	0	2-mercaptothiazole and solvent and resin and ((photoacid acid) near generator) and (basic adj compound)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/05 16:09
22	11	2-mercaptothiazole and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/05 16:09
23	0	(2-mercaptothiazole and (resist photoresist)) and (\$5acid near generat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/05 16:11
24	2	("6406830").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/05 16:40
-	182614	thiol disulfide thiolsulfonate mercapto\$	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/05 16:02
-	2424	ped (post-exposure adj delay) (post adj exposure adj delay)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:18
-	409168	resist photoresist	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:00
-	17620	((acid photoacid) near generat\$4) (photoactive near compound)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	22477	(basic adj compound) (nitrogen-containing adj compound)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	266188	surfactant	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	1095	dissolution adj inhibitor	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:00
-	98	((thiol disulfide thiolsulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay)) and (resist photoresist) and (((acid photoacid) near generat\$4) (photoactive near compound))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:01
-	98	((thiol disulfide thiolsulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay)) and (resist photoresist) and (((acid photoacid) near generat\$4) (photoactive near compound))) and "11"	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:01
-	92	((thiol disulfide thiolsulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay)) and (resist photoresist) and (((acid photoacid) near generat\$4) (photoactive near compound))) and surfactant	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:01

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-	98	((thiol disulfide thiol sulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay)) and (resist photoresist) and (((acid photoacid) near generat\$4) (photoactive near compound))) and (surfactant (dissolution adj inhibitor) ((basic adj compound) (nitrogen-containing adj compound)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:02
-	1	((thiol disulfide thiol sulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay)) and (resist photoresist) and (((acid photoacid) near generat\$4) (photoactive near compound))) and (surfactant (dissolution adj inhibitor) ((basic adj compound) (nitrogen-containing adj compound)))) and ((thiol disulfide thiol sulfonate mercapto\$) same (ped (post-exposure adj delay) (post adj exposure adj delay)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:02
-	4	(thiol disulfide thiol sulfonate mercapto\$) same (ped (post-exposure adj delay) (post adj exposure adj delay))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:06
-	97	((thiol disulfide thiol sulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay)) and (resist photoresist) and (((acid photoacid) near generat\$4) (photoactive near compound))) and (surfactant (dissolution adj inhibitor) ((basic adj compound) (nitrogen-containing adj compound)))) not ((thiol disulfide thiol sulfonate mercapto\$) same (ped (post-exposure adj delay) (post adj exposure adj delay)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:06
-	126812	\$10thiol\$10 \$10disulfide\$10 \$10thiol sulfonate\$10	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:44
-	3	(\$10thiol\$10 \$10disulfide\$10 \$10thiol sulfonate\$10) same (ped (post-exposure adj delay) (post adj exposure adj delay))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 18:38
-	6888	(\$10thiol\$10 \$10disulfide\$10 \$10thiol sulfonate\$10) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 18:40
-	71	(((\$10thiol\$10 \$10disulfide\$10 \$10thiol sulfonate\$10) and (resist photoresist)) and (((acid photoacid) near generat\$4) (photoactive near compound))) and ((basic adj compound) (nitrogen-containing adj compound)) and surfactant	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:30
-	30	(((\$10thiol\$10 \$10disulfide\$10 \$10thiol sulfonate\$10) and (resist photoresist)) and (((acid photoacid) near generat\$4) (photoactive near compound))) and ((basic adj compound) (nitrogen-containing adj compound)) and surfactant) and (dissolution adj inhibitor)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 18:41

-	25	(((((thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10) and (resist photoresist)) and (((acid photoacid) near generat\$4) (photoactive near compound)) and ((basic adj compound) (nitrogen-containing adj compound)) and surfactant) and (dissolution adj inhibitor)) not (((thiol disulfide thiolsulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay)) and (resist photoresist) and (((acid photoacid) near generat\$4) (photoactive near compound))) and (surfactant (dissolution adj inhibitor) ((basic adj compound) (nitrogen-containing adj compound)))) not ((thiol disulfide thiolsulfonate mercapto\$) same (ped (post-exposure adj delay) (post adj exposure adj delay))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:15
-	2	(ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:28
-	0	(ped (post-exposure adj delay) (post adj exposure adj delay)) near (additive)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:24
-	2430	ped (post-exposure adj delay) (post adj exposure adj delay)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:19
-	2163	(thiol disulfide thiolsulfonate) near derivative	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:43
-	0	((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) not ((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:16
-	1	(ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:19
-	21	(ped (post-exposure adj delay) (post adj exposure adj delay)) and ((thiol disulfide thiolsulfonate) near derivative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:19
-	0	2002303986.URPN.	USPAT	2003/09/03 11:23
-	705	(thiol disulfide thiolsulfonate) near agent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:24
-	10	(ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:24
-	236	(ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:29
-	1	((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:29
-	225	((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	126948	\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:39

-	11	((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10) ("6099880").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:52
-	2		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:52
-	0	20020136981.URPN.	USPAT	2003/09/03 12:07
-	112931	THIOL DISULFIDE THIOLSULFONATE	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:06
-	7137	(THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:06
-	1564	((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:17
-	121	((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:17
-	15	(US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.	USPAT; US-PGPUB; JPO	2003/09/03 14:26
-	120	((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:26
-	120	((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.)) NOT (((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)) ((acid photoacid) near generat\$4) (photoactive near compound)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:01
-	17642		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:27

-	266458	surfactant	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:27
-	0	<p>((((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.)) NOT ((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) AND (((acid photoacid) near generat\$4) (photoactive near compound)) AND surfactant</p> <p>((((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.)) NOT ((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) AND (((acid photoacid) near generat\$4) (photoactive near compound))</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:27
-	0	<p>((((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.)) NOT ((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) AND (((acid photoacid) near generat\$4) (photoactive near compound))</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:28

-	111	(((((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.)) NOT ((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) AND surfactant	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 14:42
-	0	(((((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.)) NOT ((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) AND surfactant) AND (430/\$.CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 15:04
-	5	((("5589312") or ("5344694")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 15:05
-	2	wo-9306529-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 15:06
-	7	((("5589312") or ("5344694")).PN.) or wo-9306529-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 15:06
-	8055	(430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:43
-	31	((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.) and ((thiol disulfide thiolsulfonate) near derivative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 15:22

-	31	((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.) and ((thiol disulfide thiolsulfonate) near derivative)) not (((("5589312") or ("5344694")).PN.) or wo-9306529-\$.did.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 15:22
-	31	((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.) and ((thiol disulfide thiolsulfonate) near derivative)) not (((("5589312") or ("5344694")).PN.) or wo-9306529-\$.did.)) not (((((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or US-20030039918-\$ or US-20020147259-\$).did. or (JP-2002303986-\$).did.)) NOT (((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 15:22

-	30	(((((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).cccls.) and ((thiol disulfide thiolsulfonate) near derivative)) not (((("5589312") or ("5344694")).PN.) or wo-9306529-\$.did.)) not (((((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$. or US-6395446-\$. or US-6180316-\$. or US-6280897-\$. or US-6090518-\$. or US-6399272-\$.).did. or (US-20020136981-\$. or US-20030148211-\$. or US-20030039916-\$. or US-20020058206-\$. or US-20020015916-\$. or US-20010044070-\$. or US-20030039918-\$. or US-20020147259-\$.).did. or (JP-2002303986-\$.).did.)) NOT (((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)))) NOT (((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) stabilizer	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	246076		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:51
-	12420	stabilizer and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	17642	((acid photoacid) near generat\$4) (photoactive near compound)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	22496	(basic adj compound) (nitrogen-containing adj compound)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	266458	surfactant	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 16:59
-	1096	dissolution adj inhibitor	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:00

-	42	(stabilizer and (resist photoresist)) and (((acid photoacid) near generat\$4) (photoactive near compound)) and ((basic adj compound) (nitrogen-containing adj compound)) and surfactant and (dissolution adj inhibitor)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:00
-	41	((stabilizer and (resist photoresist)) and (((acid photoacid) near generat\$4) (photoactive near compound)) and ((basic adj compound) (nitrogen-containing adj compound)) and surfactant and (dissolution adj inhibitor)) NOT (((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:01

-	41	(((stabilizer and (resist photoresist)) and (((acid photoacid) near generat\$4) (photoactive near compound)) and ((basic adj compound) (nitrogen-containing adj compound)) and surfactant and (dissolution adj inhibitor)) NOT (((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)))) not ((((((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.) and ((thiol disulfide thiolsulfonate) near derivative)) not (((("5589312") or ("5344694")).PN.) or wo-9306529-\$.did.)) not (((((THIOL DISULFIDE THIOLSULFONATE) NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT ((US-6489080-\$. or US-6395446-\$. or US-6180316-\$. or US-6280897-\$. or US-6090518-\$. or US-6399272-\$.).did. or (US-20020136981-\$. or US-20030148211-\$. or US-20030039916-\$. or US-20020058206-\$. or US-20020015916-\$. or US-20010044070-\$. or US-20030039918-\$. or US-20020147259-\$.).did. or (JP-2002303986-\$.).did.)) NOT (((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)))) NOT (((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer) ((ped (post-exposure adj delay) (post adj exposure adj delay)) same ((thiol disulfide thiolsulfonate) near derivative)) ((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol disulfide thiolsulfonate) near derivative)) (((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and (resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)))) stabilizer and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:02
-	855		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:01
-	1	(stabilizer same ((thiol disulfide thiolsulfonate) near derivative)) and (((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:53

-	53	stabilizer same ((thiol disulfide thiolsulfonate) near derivative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 17:54
-	854	(stabilizer and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)) not (stabilizer same ((thiol disulfide thiolsulfonate) near derivative))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:02
-	706	(stabilizer and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)) not (stabilizer same ((thiol disulfide thiolsulfonate) near derivative))	USPAT	2003/09/03 18:02
-	116	stabil\$6 same ((thiol disulfide thiolsulfonate) near derivative)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:50
-	4	(stabil\$6 same ((thiol disulfide thiolsulfonate) near derivative)) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:51
-	8055	(430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:43
-	2163	(thiol disulfide thiolsulfonate) near derivative	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:50
-	126948	\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:44
-	127073	((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:50
-	10164	stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:50
-	701	(stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 19:55
-	34	((stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 19:55
-	6896	((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 19:55
-	527	((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 19:55

-	493	(((((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)) not (((stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 19:55
-	233	(((((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)) not (((stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.))) and (\$5acid near generat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 19:59
-	233	((((((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)) not (((stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.))) and (\$5acid near generat\$3)) not (((stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 19:59
-	233	((((((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10)) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)) not (((stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.))) and (\$5acid near generat\$3)) not (((stabil\$6 same (((thiol disulfide thiolsulfonate) near derivative) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10))) and (resist photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.))) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917 430/921 430/942).ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 19:59